

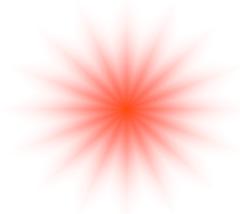
ULB

Preparation by pulsed vacuum arc deposition
and characterization of DLC/MoS₂
nanocomposite thin films

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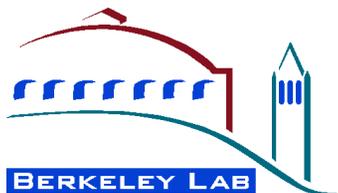
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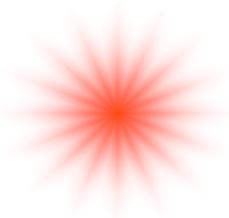
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Outline

- Why DLC + MoS₂ nanocomposites
- Set-ups
- Thermodynamics
- C + Mo + CS₂: bonding
- Mo + S:
 - Bonding and structure
 - Ball-on-disk tests under air and dry nitrogen
- Mo + S + C:
 - Bonding and structure
 - Ball-on-disk tests under air and dry nitrogen
- Comparison with other systems and conclusions

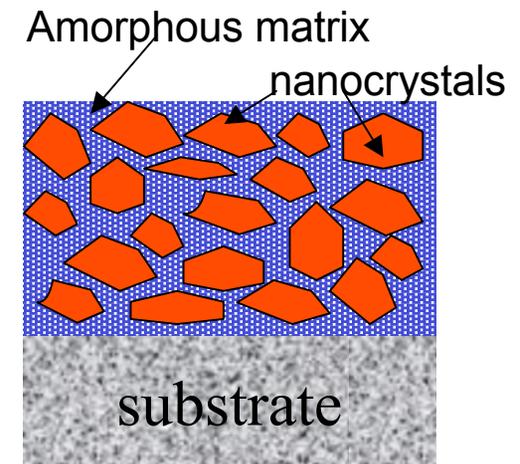


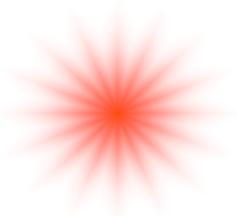


Why DLC + MoS₂ nanocomposites

- Lubrication performances of non-hydrogenated DLC are limited in absence of moisture but good hardness and toughness
- MoS₂ = good lubricant under dry conditions or under vacuum but low hardness, and oxydation in presence of O₂ or H₂O

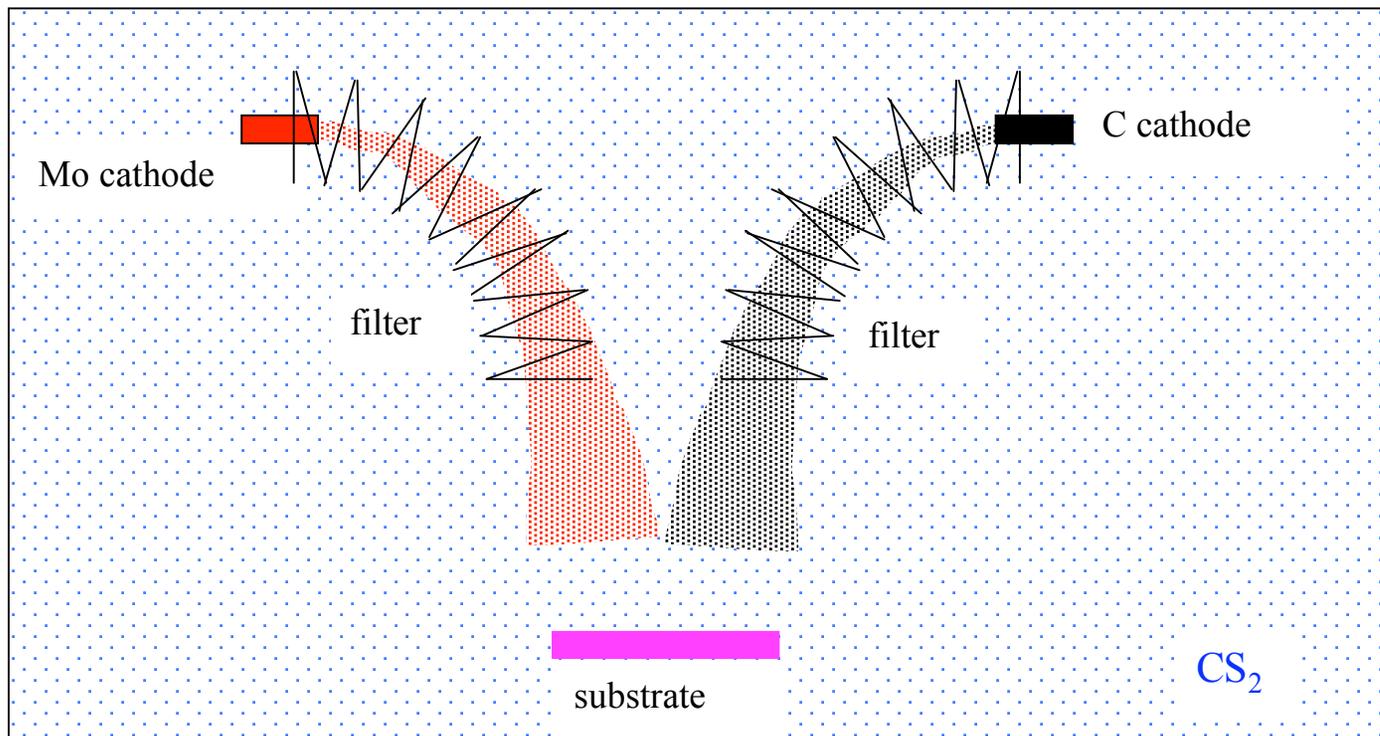
=> idea: incorporate clusters of MoS₂ in a matrix of DLC to get a film with good performances under wet and dry conditions.

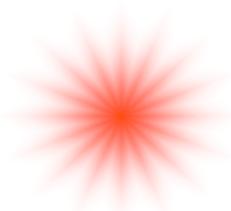




Set-up: gaseous source of Sulfur

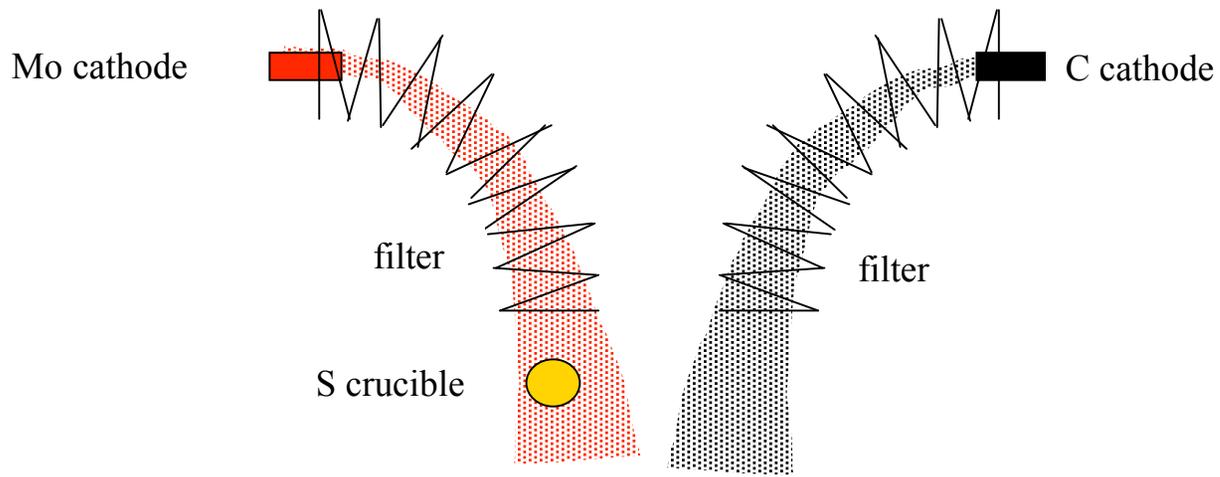
- Gaz source for S = CS_2





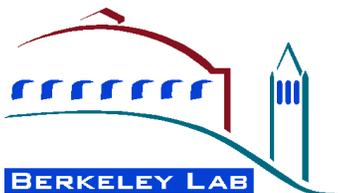
Set-up : solid source of Sulfur

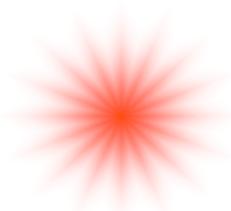
- Evaporation of solid sulfur in a crucible



substrate

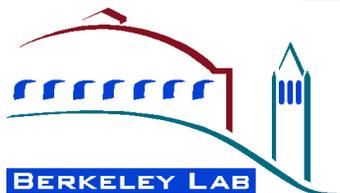
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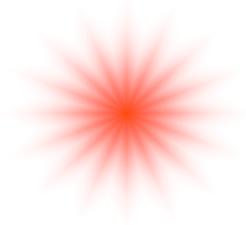




Thermodynamics

Compound	Enthalpy of formation (at 298 K)
MoS_2 solid	-276.010 kJ

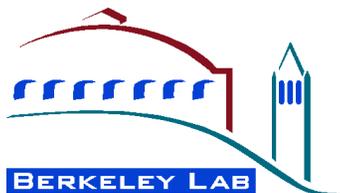


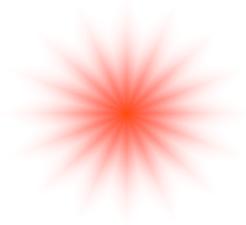


In absence of S source

-
- C pulse 4 ms at 270A,
Mo pulse 6 ms at 100A

=> formation of
molybdenum carbide

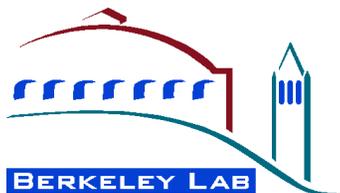


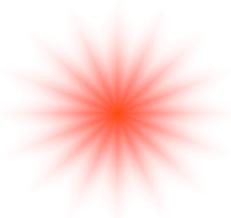


Films prepared with CS₂

- C pulse 4 ms at 270A,
Mo pulse 6 ms at 100A
1 Pa of CS₂

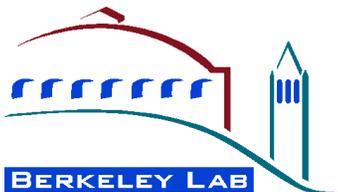
=> - very low incorporation of sulfur
- difficulty to control the Mo/C and S/C ratios
- sensitivity to contamination

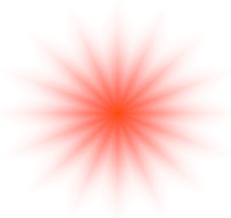




Mo + S synthesis: bonding

- sulfur is incorporated exclusively if Mo is present
- a bias on the substrate reduces the incorporation of sulfur in the film. Two factors:
 - preferential sputtering of sulfur under Mo^{n+} ion bombardment
 - the bias attracts the Mo^{n+} ions but as the ionization of sulfur is low, the bias is not attracting the sulfur
- the structure is not well ordered: wide peaks in XPS



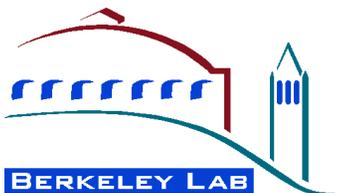


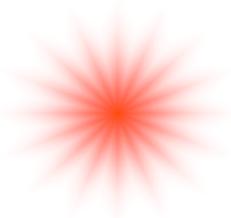
MoS₂ synthesis: mechanical properties

- Ball-on-disk tests in dry N₂, Al₂O₃ ball
 - life time increased by a factor of 4 in comparison with air tests
 - failure by delamination and intensive cracking

=> very brittle films

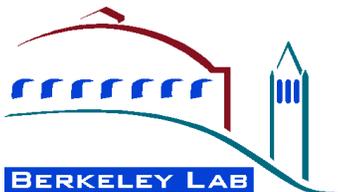
=> not satisfactory as lubricants even under dry N₂

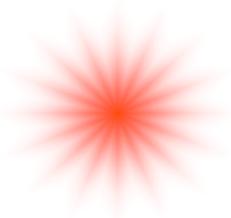




Mo + S + C: bonding

- S bonded mainly to Mo.
- No real proof of C-S bonds even in presence of an excess of S
- possible S-S bonds in presence of an excess of S
- in presence of an excess of Mo formation of MoO₃ at the surface and tendency to form Mo-C bonds in the bulk
- reduction of S incorporation in presence of bias

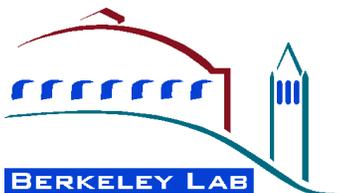


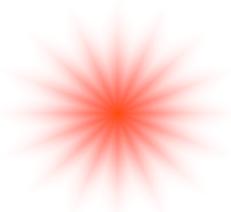


Mo + S + C: mechanical properties

- Ball-on-disk tests with stainless steel and alumina balls in air
 - Ball-on-disk tests with alumina balls in dry N₂
- => best resistance to abrasion in air and dry N₂ for low concentration of MoS₂ (doping).
- => at low concentration of MoS₂ (doping), better resistance to abrasion with a steel ball than with Al₂O₃ ball
- => performances are lower in air than pure DLC films
- => films with high MoS₂ concentration are brittle and don't support the load: extensive cracking and delamination

NO improvement of the tribological performances of DLC by the addition of MoS₂ in the deposition conditions investigated here.





Comparison with other systems and conclusions

- The MoS₂ / DLC system has been compared with W doped DLC and Ti doped DLC films prepared in similar conditions:

=> W and Ti additions reduce the intrinsic compressive stress of the hard DLC films and made them tougher.

=> addition of MoS₂ does not improve the performances of doped DLC films, it increases the brittleness: could be related to the bonding in the films.

